Considerations for 3D EBSD

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EBSD – Probably the Best Measurement in the World

Austin Day, Microscopy & Microanalysis, 11, 502-503 (2005)







- Introduction to EBSD
- 3D Data Acquisition Serial Sectioning
- Practical considerations for EBSD
- CdTe PV Case Study
- Conclusions



EBSD



Electron backscatter diffraction patterns (or EBSPs) are obtained in the SEM by focusing a stationary electron beam on a crystalline sample. The sample is tilted to approximately 70 degrees with respect to the horizontal. The diffraction pattern is imaged on a phosphor screen. The image is captured using a low-light CCD camera. The bands in the pattern represent reflecting planes in the diffracting crystal volume. Thus, the geometrical arrangement of the bands is a function of the orientation of the diffracting crystal lattice.















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EBSD - Hardware



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EBSD – Two Main Application Areas





Phase Identification





EBSD – Phase ID





Candidate Phases

Fe ₂ TiO ₄	Cubic	a=11.297
Fe-Ti-O	Cubic	a=11.31
Fe ₄ (TiO ₄) ₃	Tetragonal	a=9.3, c=9.5
FeTiO3	Trigonal	a=5.0884, c=14.093
Fe ₂ TiO ₄	Cubic	a=8.5352
Fe3Ti3O10	Orthorhombic	a=7.789, b=10.008,
		c=3.74162
FeTiO3	Orthorhombic	a=5.026, b=5.174,
		c=7.245
Fe ₂ Ti ₃ O ₉	Hexagonal	a=2.8667, b=4.5985









Phase ID







EBSD – Two Main Application Areas











Orientation Imaging Microscopy - OIM



In an OIM scan the beam is stepped across the sample surface in a regular grid. At each point the EBSP is captured and automatically indexed and the orientation and other information recorded (such as the quality of the EBSP, an indexing reliability factor, the secondary detector intensity, EDS data...)



Orientation Maps

- An Orientation Map is generated by shading each point in the OIM scan according to some parameter reflecting the orientation at each point.
- A Grain Boundary Map can be generated by comparing the orientation between each pair of neighboring points in an OIM scan. A line is drawn separating a pair of points if the difference in orientation between the points is within a specified range.





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Texture



111 Pole Figure and corresponding OIM Map from an Aluminum Thin Film



10 μ**m**



Residual Strain

Pattern Quality

-Dark regions are strained -Light regions are recrystallized



37.50 µm = 50 steps IQ 10.4...57.8

Local Misorientation

- Subtle changes in color



37.50 µm = 50 steps IPF







Electron Backscatter Diffraction

- Spatial resolution (~20nm)
- Angular resolution (~0.3°)
- Automation (~500pps)









Sample Conditions



Sample Preparation





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Atomic Scattering Factor







EBSPs obtained at 1.92s exposure time (no image processing)

Tantalum



Microscope Conditions

Probe Size (FE vs. LaB₆ vs. Tungsten) Operating Conditions (**Current**, Voltage, Vacuum) Video Settings (Exposure, gain, contrast & brightness)



0.6nA Beam Current 4.62 Seconds



2.4nA Beam Current 1.56 Seconds



9.45nA Beam Current 0.6 Seconds



Microscope Conditions – Voltage Effect

Probe Size (FE vs. LaB₆ vs. Tungsten) Operating Conditions (Current, **Voltage**, Vacuum) Video Settings (Exposure, gain, contrast & brightness)





Si at 10 kV and 30 kV





EBSD Spatial Resolution

Interaction Volume

- Spot Size

Current generally increases with increasing spot size

- Current

~5nA (1-10nA)

- Voltage

Seems to effect depth more than lateral resolution 5-30 kV

- Material

Higher Z materials are better reflectors

Operating Conditions
Drift vs. Speed



"Average" Pattern





Serial Sectioning

Use of Combined SEM/FIB with EBSD







In-Situ Milling

milling strategy: grazing-incidence edge-milling



feature has to be at edge

milling strategy:

low-incidence surface-milling



large milling areas required to avoid shadowing of EBSD edge-milling Fe-Si





Serial Sectioning

EBSD surface – orientation mapping



Platinum Cap – to prevent curtaining



Fiducial marks – for re-alignment between stage moves. (Atop platinum for improved contrast)



SEM View

FIBView



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Indexing Details

- Helpful to understand what is happening in the algorithms so an operator can better make adjustments to optimize the results
- The algorithms between the EBSD vendors differ from each other but the underlying principles are similar.



Q. How do we find the bands? Hough Transform





A given pixel in an image could belong to an infinite set of lines. A line can be parameterized by the Hough parameters r and q. Where q describes the angle of the line and r represents the perpendicular distance of the line from the origin. The relationship between the lines passing through a pixel at a coordinate in the image of x, y can be expressed as: $r = x\cos q + y\sin q$. This means a point in image space transforms to a sinusoidal curve in Hough space.





Consider 4 pixels along a line. For each pixel in the line, all possible ρ values are calculated for θ 's ranging in values from 0 to 180 degrees using the equation: $\rho = x \cos \theta + y \sin \theta$. This produces 4 sinusoidal curves. This curves intersect at a point at a ρ , θ coordinate corresponding to the angle of the line (θ) and its position relative to the origin (ρ). Thus, a line in the pattern space transforms to a point in Hough Space.







An entire image can be transformed into Hough Space by building an accumulator array $H(\rho,\theta)$ where, for each pixel in the image, all possible r values are calculated for θ 's ranging in values from 0 to 180 degrees via the equation $\rho = x\cos\theta + y\sin\theta$. The intensity value of the pixel at *x*, *y* is then added to the bin in the array at each corresponding ρ , θ . (Strictly speaking the Hough Transform only applies to binary images - this adaptation is the Radon Transform).









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A set of orientations is obtained from a triplet of bands by comparing the interplanar angles against a look-up table.



Angle	(hkl) ₁	(hkl) ₂
25.2	200	311
29.5	111	311
31.5	220	311
35.1	311	311
35.3	111	220
45.0	200	220
50.5	311	311
54.7	111	200
58.5	111	311
60.0	220	202
63.0	311	131
64.8	220	311
70.5	111	111
72.5	200	131
80.0	111	311
84.8	311	131
90.0	111	220
90.0	200	020
90.0	200	022
90.0	220	113
90.0	220	220





Now allow a little bit of "wiggle" by setting the *interplanar angle tolerance* to 5 degrees. Let the "red" angle be measured as 55 degrees, the "blue" as 59 degrees and the green as 72 degrees. Now, multiple solutions can exist for the triplet.







For a set of three bands, compare the interplanar angles against the LUT and determine all possible indexing solutions.

Solution 1









$$\#triplets = \frac{n!}{(n-3)! \cdot 3!}$$

For a given number of bands, *n*, used for pattern indexing, the number of band triplets is determined by this formula.

Typically 7 to 9 detected bands are used for automatic indexing.

п	# triplets
3	1
4	4
5	10
6	20
7	35
8	56
9	84



Indexing: Bands – Triplet Voting



For this set of 5 detected bands, 10 triplet combinations are possible. For each of these 10 triplets, solution V_1 matched. Solutions V_2 and V_3 each matched one triplet only.



Indexing: Bands – Triplet Voting



 $Fit = 0.26^{\circ}$

Solution V_1 . Notice how each of the 5 bands match bands in the indexing solution overlay.



Indexing: Bands – Triplet Voting



 $Fit = 1.30^{\circ}$

Solution V_2 . Only the red, yellow, and magenta band triplet now match, producing a higher fit value.



Indexing: Bands – Confidence Index

Triplet	Solution 1 (<i>V</i> ₁)	Solution 2 (V ₂)	Solution 3 (V_3)
RGY	Х		
RGB	X		
RGM	Х		
R Y B	X		
RYM	Х	X	
R B M	Х		
GYB	Х		
GYM	Х		
GBM	Х		
YBM	Х		X
Total	10	1	1

 $CI = \frac{V_{1} - V_{2}}{V_{ideal}}$





The confidence index, *CI*, measures the uniqueness of an orientation solution relative to the total number of possible votes.



Indexing: Bands – Confidence Index



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Indexing: Deconvoluting Patterns



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Indexing: Deconvoluting Patterns & Cl





Optimizing EBSD

Speed

- Pretty patterns vs. scanning patterns
- Camera

Binning Gain

- Image Processing
- Hough Settings
 Convolution Mask
 dTheta

Speed vs. Quality

- Indexing success rate
- Precision
- Clean-up



Pretty Pictures









CCD Camera Binning



4x4 - 120x120



8x8 - 60x60

5x5 - 96x96



10x10 - 48x48





How Binning Works



Binning reduces the number of pixels in the final image, and increases the effective image intensity.



CCD Camera Binning





Maximum Frame Rate (FPS)					
4x4 (128x128)	543				
5x5 (96x96)	640				
6x6 (80x80)	732				
8x8 (60x60)	881				
10x10 (48x48)	1000				

Faster camera frame rates are possible with binned images.



1x1

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Precision vs. Binning





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Indexing Rate vs. Binning



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Camera Gain



Minimum Gain 2.76 Seconds

Mid-Range Gain 0.55 Seconds Maximum Gain 0.15 Seconds

As gain goes up, exposure time goes down, however, the signal to noise ratio decreases.



1x1 Binning (480x480 Pixels)



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5x5 Binning (96x96 Pixels)



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10x10 (48x48 Pixels)



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5x5 (96x96 Pixels) Spread & Indexing Rate

	0% Gain	20% Gain	40% Gain	60% Gain	80% Gain
Orientation Spread	0.12°	0.13°	0.18°	0.26°	0.40°
Indexing Success Rate	100%	100%	97.1%	24.8%	0.8%

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SEM Settings – Beam Current



Note however that the gain required for an EBSD pattern is inversely related to the amount of incident beam current.



Image Processing



We usually have to do some image processing of the patterns to get uniform intensity across the pattern so that the automated band detection algorithms can do a good job.



Dynamic Background Correction

Blur

Helpful for single crystals or very rough surfaces or also for multiphase samples where the individual phases produce patterns with very different intensity. Any defects in the phosphor screen remain. Slower than static background correction. Both can be used together.



Other Image Processing

Image Processing Recipe Builder

a.

=

Remove

OK



Other image processing can be done as well but this tends to slow the whole process down and generally isn't necessary to get good indexing and band detection.

Load

Cancel

Save

Contrast [50%]





5x5 (96x96 Pixels) With Frame Averaging



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Hough Transform



After convolution with Butterfly Mask







Hough Transform





Mask Size & Band Width

Binning







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Hough Theta Step



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5x5 (96x96 Pixels) Average Orientation Spread

	0% Gain	20% Gain	40% Gain	59% Gain Max FPS	60% Gain	80% Gain
0.5°θ	0.12°	0.13°	0.18°	0.27°	0.26°	0.40°
1° Ө	0.16°	0.17°	0.20°	0.27°	0.27°	0.40°
2° Ө	0.17°	0.20°	0.29°	0.38°	0.38°	0.48°
З° Ө	0.13°	0.13°	0.22°	0.33°	0.34°	0.57°

Less than 60% gain is necessary for maximum FPS



10x10 (48x48 Pixels) Orientation Spread

	0% Gain	20% Gain	40% Gain	41% Gain Max FPS	60% Gain	80% Gain
0.5°θ	0.21°	0.26°	0.41°	0.42°	0.93°	NA
1°θ	0.21°	0.27°	0.48°	0.49°	0.99°	NA
2° Ө	0.26°	0.28°	0.50°	0.46°	1.09°	NA
3° Ө	0.29°	0.44°	0.78°	0.80°	1.55°	NA

Near 40% gain is necessary for maximum FPS



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10X10 Points Correctly Indexed

	0% Gain	20% Gain	40% Gain	41% Gain Max FPS	60% Gain	80% Gain
0.5°θ	100%	100%	96.7%	97.4%	28.7%	0.9%
1°θ	100%	100%	97.1%	95.3%	24.8%	0.8%
2°θ	100%	99.9%	93.1%	92.2%	12.1%	0.7%
3° Ө	100%	99.1%	72.7%	75.2%	3.9%	0.8%

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Summary and Conclusions

- High frame rates are achieved through camera binning and camera gain settings.
- Hough settings must be optimized for a given camera setting. Set up Hough parameters for patterns obtained under scan conditions, not for patterns obtained in a high quality pattern mode.
- There is a trade-off between speed and orientation precision but not as severe as one might assume. Trust the Hough!
- Evaluate the quality of the results on the quality of the scan data not how the pattern looks.
- Note that these results have been shown in diamond cubic silicon and FCC nickel.
- Non-cubic patterns may require higher resolution, to achieve accurate band detection.
- Recently submitted a manuscript on precision with a particular focus on precision at grain boundaries.



Confidence Index Partitioning or Filtering



CI>0.3

We can filter the data based on CI or Fit or other metrics to mask data we do not have confidence in from our subsequent analysis. However, some of these low CI points are actually valid orientations. How can we recover them?



Initial Confidence Index Distribution





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Confidence Index Standardization





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Confidence Index Standardization



As-collected

CI>0.3 91.8%

Grain CI Standardization

CI>0.3 98.7%

The confidence index standardization (CIS) routine identifies the maximum fraction of correctly indexed points. <u>Use it always.</u>





Grain Dilation

This clean up method is an iterative method. The routine only acts on points that do not belong to any grains; yet have neighboring points, which do belong to grains. A point may not belong to any grain due to the point either not being indexed or due to it belonging to a grain group having fewer members than the Minimum Grain Size. If the majority of neighbors of a particular point belong to the same grain then the orientation of the particular point is changed to match that of the majority grain - otherwise the orientation is randomly changed to match any of the neighboring points, which belong to grains. This process is repeated until each point in the data set becomes a member of a grain. (Alternatively, the user may set the code to only perform a single iteration.) In the schematic below, in the left hand figure the data point in white is not part of any grains. After dilation it's orientation is changed to match that of the neighboring member of the green grain with the highest CI.





Grain Dilation



Cl > 0.1 - 95.5%



2 Iterations -99.7% +4.2%





1 Iteration -99.6% +4.1%

3 Iterations -99.7% +4.2%





Grain Dilation

Grain Dilation can actually work too well. Plausible microstructures can be generated out of nearly random data.



Full Grain Dilation Cleanup





Summary

- There are a wide range of tools available to identify the correctly indexed points and remove noise within the data maps.
- The Grain CI Standardization feature should always be used in conjunction with a CI filter to determine indexing quality.
- Cleanup routines should be used with care to improve data quality and results and not introduce artificial data.
- It is good practice to report the cleanup used during analysis and the fraction of points cleaned.
- Start with the best data possible!









Photovoltaic Materials

- Energy demand and prices are expected to increase and the demand for alternative sources is high.
- Photovoltaic thin film solar cells provide a commercially viable technology. Thin film photovoltaic devices use only a small fraction of the raw material when compared to traditional cells.
- Polycrystalline CdTe and CIGS thin films have higher efficiencies than single crystal devices.
- The performance of these thin films is influenced by the crystallographic structure, grain boundary character, and grain size.





Photovoltaic Materials

- Cadmium Telluride
 - Cubic (FCC)
- Cadmium Sulfide
 - Cubic (FCC)
 - Hexagonal
- Indium Oxide
 - Cubic (FCC)
- Tin Oxide
 - Tetragonal
- Silicon Oxide
 - Trigonal





Phase Differentiation Challenges

EBSD pattern Cubic (Oh) [m3m]

Indexed as CdTe

Indexed as In_2O_3





Photovoltaic Materials

- Cadmium Telluride
 - Cubic (FCC)
- Cadmium Sulfide
 - Cubic (FCC)
 - Hexagonal
- Indium Oxide
 - Cubic (FCC)
- Tin Oxide
 - Tetragonal
- Silicon Oxide
 - Amorphous





EBSD Phase Mapping







EDS RGB Element Mapping









EDS Phase Mapping









EDS Phase Mapping









Chemistry assisted indexing





Chemistry assisted indexing - Notes

- Using the counts of individual elemental ROIs is faster than using full spectral analysis and is effective and efficient on these materials.
- Need to resolve "intermediary" phases
- High-Tilt EDS







EBSD & EDS phase mapping



 In_2O_3

CdS (Hexagonal)



CdTe

ANTE LER

EDS at EBSD Geometry

Azimuthal Angle (°)	Sample Tilt (°)	CPS (Normalized)
NA	0	1.00
0	70	1.44
15	70	1.36
30	70	1.31
45	70	1.22

- Tilting the specimen increases the EDS count rate due to reduced absorption
- The improved count rate is often beneficial for simultaneous EDS-EBSD mapping



Effect of Working Distance on EDS Signal



 A special EDS electron trap was designed to allow EDS detection over an extended WD range.

- For simultaneous EDS and EBSD data collection, both detectors need to be aimed at the same working distance.
- EBSD data is often collected away from the optimal EDS analytical working distance depending on the sample size and geometry







EDS Detection Improvement





EDS Detection Improvement





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eZAF Quantification Results

RMS (%) Fe ₂ 0 ₃	0°	15°	30°	45 °
ZAF	6.3	6.5	7.6	9.1
eZAF	1.4	1.3	0.3	1.1

• Significant improvement for "difficult" sample compared to old ZAF routine





EBSD and EDS interaction volumes







EDS and EBSD Interaction Volume





EDS and EBSD Interaction Volume





EBSD and EDS interaction volumes







🗖 1µm



3D Reconstruction – Phase map (EDS)



Data collected on a Zeiss Ariga with the help of Hubert Schulz





3D Reconstruction – Orientation Map (EDS + EBSD)











